Substitute	Form	PTO-1449
(Modified)		

U.S. Department of Commerce Patent and Trademark Office Attorney's Docket No. 12732-051002

Application No. 10/727,651

Information Disclosure Statement by Applicant (Use several sheets if necessary) Applicant
Shunpei Yamazaki, et al.

(37 CFR §1.98(b))

Filing Date Group Art Unit December 5, 2003 2826

## **UPDATED VERSION**

U.S. Patent Documents					<del></del>		
Examiner	Desig.	Document	Publication		Class	Cubalasa	Filing Date
Initial /AS/	ID AA	Number 4,766,477	Date 08/23/1988	Patentee Nakagawa, et al.	Class	Subclass	If Appropriate
	AB	5,643,826	07/01/1997	Ohtani, et al.			
	AC	5,923,962	07/13/1999	Ohtani, et al.			
	AD	5,943,560	08/24/1999	Chang, et al.			
	AE	5,977,560	11/02/1999	Banerjee, et al.			
	AF	6,087,679	07/2000	Yamazaki, et al.			
	AG	US 2002/0043662	04/18/2002	Yamazaki, et al.	<del></del>		
	AH	US 2002/0038889	04/04/2002	Yamazaki, et al.			
	AI	US 2002/0014625	02/07/2002	Asami, et al.			
	AJ	US 2002/0008286	01/24/2002	Yamazaki, et al.			
	AK	US 2002/0040981	04/2002	Yamazaki, et al.			
	AL	US 2003/0001159	01/02/2003	Ohtani, et al.	-		
	AM	5,162,933	11/10/1992	Kakuda, et al.			
	AN	5,304,407	04/19/1994	Hayashi, et al.			
	AO	5,602,424	02/1997	Tsubouchi, et al.			
	AP	5,686,980	11/11/1997	Hirayama, et al.			
	AQ	5,932,893	08/03/1999	Miyanaga, et al.	-		
	AR	6,107,639	08/22/2000	Yamazaki, et al.			
	AS	6,107,654	08/22/2000	Yamazaki, et al.			
	AT	6,180,957	01/30/2001	Miyasaka, et al.			
	AU	6,285,042	09/04/2001	Ohtani, et al.	-		· · · · · · · · · · · · · · · · · · ·
	AV	6,307,214	10/23/2001	Ohtani, et al.			
				Yamazaki			1
	AW	6,307,220	10/23/2001 01/01/2002	Ohtani, et al.	<u> </u>		
	AY	6,348,368	02/19/2002	Yamazaki, et al.			
	AZ	6,452,211	02/19/2002	Ohtani, et al.			
.\	AL.	0,432,211	09/1//2002	Ontam, et al.	-	<u> </u>	<u> </u>

Examiner Signature /A Sefer/	Date Considered	09/11/2007
EXAMINER: Initials citation considered. Draw line through citation if no next communication to applicant.	t in conformance and not	considered. Include copy of this form with

Substitute Form PTO-1449 (Modified)  U.S. Department of Commerce Patent and Trademark Office  Information Disclosure Statement by Applicant (Use several sheets if necessary)  (37 CFR §1.98(b))				Application No. 10/727,651		
			Applicant Shunpei Yamaza	Applicant Shunpei Yamazaki, et al.		
			Filing Date December 5, 200	Group Art Unit 2826		
( IASI ) B.	A 6,495,	386 12/17/2002	Yamazaki, et al.	06/13/200	)2	
B	В					

Foreign Patent Documents or Published Foreign Patent Applications								
		Document Publication		Country or		٠	Transla	tion
Initial	ID	Number	Date	Patent Office	Class	Subclass	Yes	No
	BC	8-78329	03/22/1996	Japan			Abstract	
	BD	7-130652	05/19/1995	Japan			Abstract	
	BE	TW 251379	07/11/1995	Taiwan			Full	
	BF	TW 310478	07/11/1997	Taiwan	1.		Abstract	
	BG	JP 11-345767	12/1999	Japan			Abstract	
	BH	JP 4-349619	12/1992	Japan			Abstract	
	BI	EP 984317	03/2000	Europe			In English	
	ВЈ	02-219234	08/31/1990	Japan			Abstract	
	BK	11-204434	07/30/1999	Japan			Abstract	
	BL	11-284198	10/15/1999	Japan			Abstract	
	BM	11-307783	11/05/1999	Japan			Abstract	
	BN	EP 510969	10/28/1992	Europe			In English	
	ВО							

		Other D	ocuments (include Author, Title, Date, and Place of Publication)
	Examiner	Desig.	
- 1	Initial	l ID	Document
$\langle$	/AS/	BP	R. Ishihara et al.; "Micro Texture Analysis Of Location Controlled Large Si Grain Formed by Exciter-Laser Crystallization Method"; AMLCD '99 Digest of Technical Papers 1999 Tokyo, Japan; pp. 99-102; 1999
	/AS/	ВQ	Seok-Woon Lee et al.; "Low Temperature Poly-Si Thin-Film Transistor Fabrication by Metal-Induced Lateral Crystallization"; <i>IEEE Electron Device Letters, Vol. 17, No. 4</i> , pp. 160-162; April 1996
		BR	·

Examiner Signature	Date Considered	
/A Sefer/		09/11/2007
EXAMINER: Initials citation considered. Draw line through citation if no next communication to applicant.	ot in conformance and not	
		Cubatituta Diodesura Form (DTO 1440)